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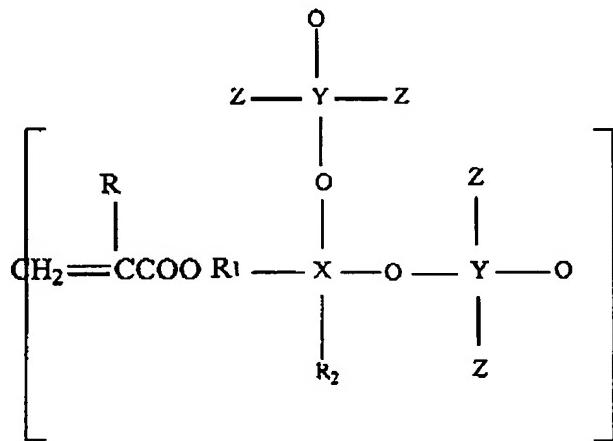
CLAIM LISTING

1. (Currently Amended) A process for producing a non-aqueous sol-gel spin-on glass material comprising a hybrid glass/polymer material, by reacting an alkyl substituted trialkoxysilane or dialkyl substituted dialkoxy silane with a silane diol, wherein said alkyl group has from 1 to 8 carbon atoms, wherein the reaction of the alkyl substituted trialkoxysilane or dialkyl substituted dialkoxy silane with the silane diol is carried out in a non-aqueous medium in the presence of a catalyst, wherein the catalyst is selected from: a) a tin catalyst or b) a dibutyltin dilaurate, titanium isopropoxide, acetic acid or trifluororoacetic acid catalyst.
2. (Original) The process of claim 1, wherein the silane diol is a diphenylsilanediol, a 1,3-Bis (3-hydroxypropyl) tetramethoxysilane, a 1,3-Bis (4-hydroxybutyl) tetramethylsilane, a fluorinated silane diol, or a mixture of one or more of these silane diols.
3. (Original) The process of claim 1, wherein the alkyl group is replaced with a methacryloxypropyl, acryloxypropyl, or epoxy moiety.
4. (Canceled) The process of claim 1, wherein the trialkoxysilane or dialkoxy silane has one or more C₁ to C₈ alkyl, methacryloxypropyl and/or alkoxy groups on the same molecule.
5. (Original) The process of claim 1, wherein the trialkoxysilane or dialkoxy silane has 1 to 3 C₁ to C₈ alkyl, methacryloxypropyl and/or alkoxy groups on the same molecule.
6. (Canceled) The process of claim 1, further comprising adding an inorganic or organic dopant.
7. (Original) The process of claim 1, further comprising adding a phosphor dopant.

8. (Currently Amended) The process of claim 7, wherein the phosphor dopant comprises YAG base phosphor or moisture sensitive phosphor nano-particles or an organic material selected from organic dyes or metal complexes.
9. (Original) The process of claim 1, further comprising adding a UV light blocking material and/or an oxygen scavenger.
10. (Original) The process of claim 1, further comprising adding a light-scattering material.
11. (Original) The process of claim 1, further comprising adding a coupling agent.
12. (Original) The process of claim 11, wherein the coupling agent is a dibutoxyaluminoxytriethoxysilane, a mixture of zirconium isopropoxide and methacrylic acid, or another transition metal propoxide.
13. (Canceled) The process of claim 1, comprising the reaction of an alkoxy silane with an organic diol in a non-aqueous medium in the presence of a catalyst.
14. (Canceled) The process of claim 1, wherein the catalyst is a tin catalyst.
15. (Canceled) The process of claim 1, wherein the catalyst is dibutyltin diluariate, titanium isopropoxide, acetic acid or trifluororoacetic acid.
16. (Canceled) The process of claim 1, further comprising adding a coupling agent.
17. (Canceled) The process of claim 1, wherein the coupling agent is a dibutoxyaluminotriethoxysilane, a mixture of zirconium isopropoxide and methacrylic acid, or another transition metal propoxide.

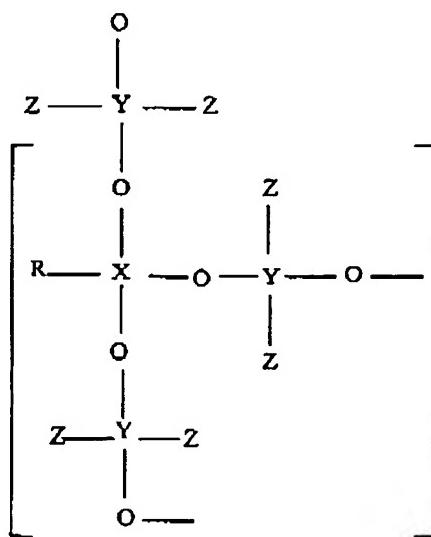
18. (Currently Amended) A non-aqueous sol-gel spin-on glass material comprising a hybrid glass/polymer material containing a dopant, which comprises YAG base phosphor or moisture sensitive phosphor nano-particles, or an organic material selected from organic dyes or metal complexes, said sol-gel spin-on-glass material selected from the group having the following formulas:

Formula I



Where R = Hydrogen, C₁-C₈ Alkyl, Halogenated C₁-C₈ Alkyl or Glycidyloxyalkyl
 R₁ = Ethyl, Propyl, another C₁-C₈ Alkyl, Halogenated C₁-C₈ Alkyl, Phenyl or Halogenated Phenyl
 R₂ = Methyl, Ethyl or another C₁-C₈ Alkyl
 X, Y = Si, Ge, Ti or Sn
 Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

Formula II

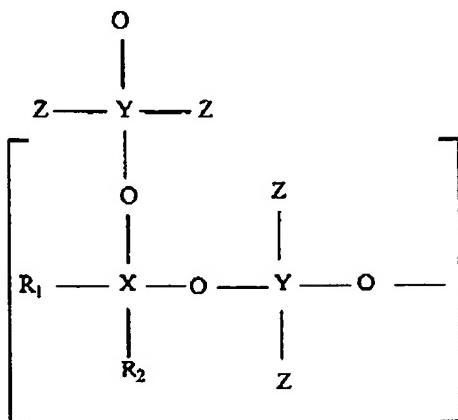


Where R = Alkyl (C₁-C₈), Phenyl, Substituted Phenyl

X, Y = Si, Ge or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

Formula III



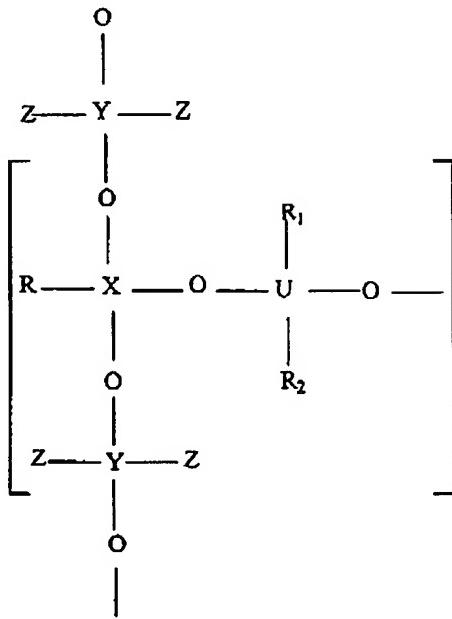
Where R₁ = Phenyl, Ethyl, Propyl, Trifluoropropyl

R₂ = Methyl, Ethyl

X, Y = Si, Ge, Ti or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl

Formula IV



Where R = Alkyl (C₁-C₈), Phenyl, Substituted Phenyl

R₁ = Alkyl, Phenyl

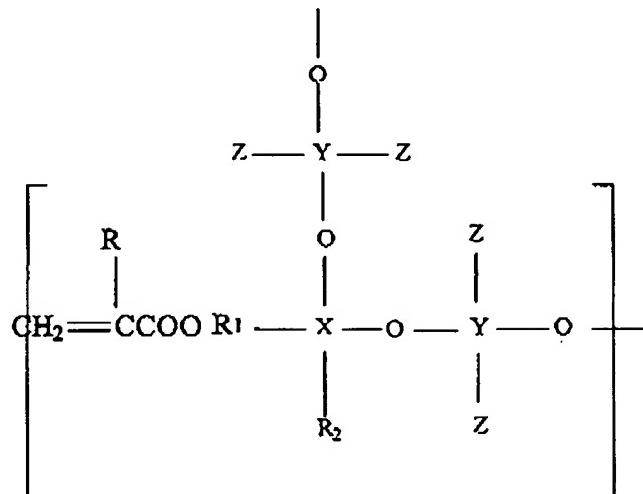
R₂ = Alkyl, Phenyl

X, U, Y = Si, Ge, Ti or Sn

Z = Alkyl, Substituted Alkyl, Phenyl, Substituted Phenyl.

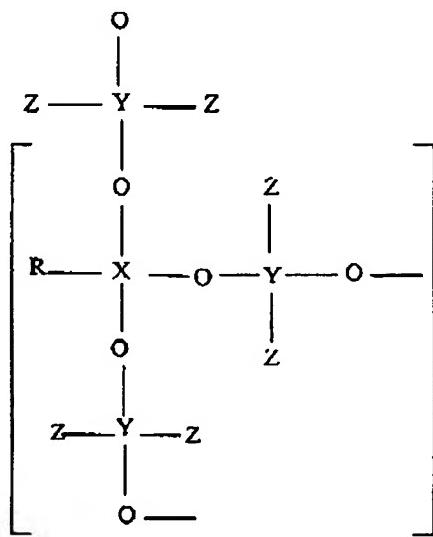
19. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, having the following formula:

Formula I



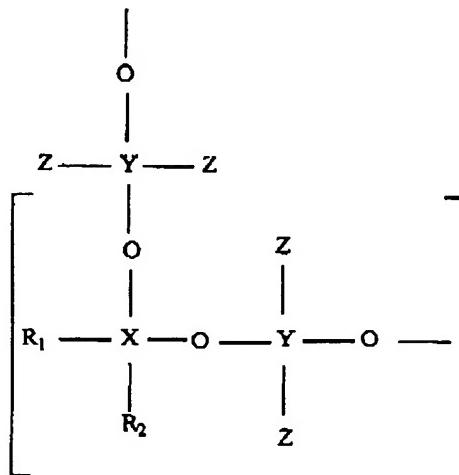
20. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, having the following formula:

Formula II



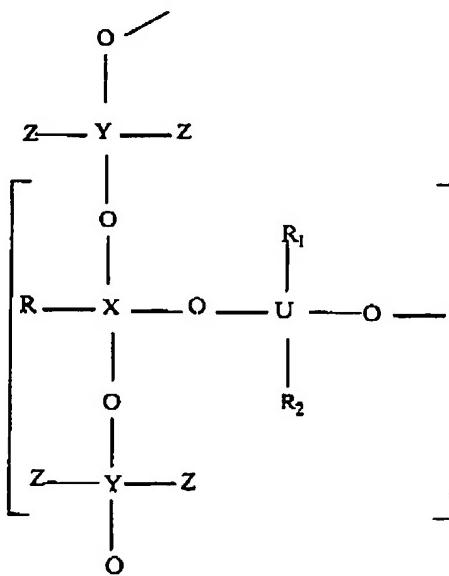
21. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, having the following formula:

Formula III



22. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, having the following formula:

Formula IV



23. (Canceled) The non-aqueous sol-gel spin-on-glass material of claim 17, further comprising an inorganic or organic dopant.

24. (Canceled) The non-aqueous sol-gel spin-on-glass material of claim 22, wherein the dopant comprises a phosphor dopant.

25. (Canceled) The non-aqueous sol-gel spin-on-glass material of claim 22, wherein the dopant comprises a YAG base phosphor, a moisture sensitive phosphor, nano-particles, or an organic material such as an organic dye or a metal complex.

26. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, further comprising a UV light blocking material and/or an oxygen scavenger.

27. (Currently Amended) The non-aqueous sol-gel spin-on glass material of claim 18, further comprising a light-scattering material.

28. (Withdrawn/Currently Amended) A process for patterning the non-aqueous sol-gel spin-on glass material of claim 17 comprising: a) coating a substrate with said material followed by soft baking at 110°C (1hr), 120°C (1-2 hr); b) exposing the coated substrate of step a) to UV illumination in a desired pattern; c) post-exposure baking the coated substrate of step b) at a temperature from 100°C to 120°C for 30 to 60 minutes; d) cooling the coated substrate of step c) to room temperature; e) removing the non-exposed areas of the coating on the coated substrate of step d); f) drying the coated substrate of step e); g) hard baking the coated substrate of step f) at a temperature from 120 °C and 150 °C for 1 to 3 hours.

29. (Withdrawn/Currently Amended) The process of claim 28, wherin the non-exposed areas of the coating on the coated substrate are removed by developing in a suitable organic solvent.

30. (Withdrawn/Currently Amended) The process of claim 29, wherein in step e) the organic solvent is tetrahydrofuran, methylethylketone, acetone, n-propylacetate, or mixture of these solvents.

31. (Withdrawn/Currently Amended) The process of claim 28, wherein in step f) the coated substrate is dried by flushing with a non-reactive gas.

32. (Withdrawn/Currently Amended) The process of claim 28, wherein in step a) the substrate is glass, quartz, sapphire, silicon, a metalized substrate or a polymeric film.

33. (Withdrawn/Currently Amended) The process of claim 28, wherein in step a) the coating is carried out by spin coating, dip coating, spray coating or doctor blade coating.

34. (New) The non-aqueous sol-gel spin-on glass material of claim 18, wherein the phosphor dopant comprises YAG base phosphor or moisture sensitive phosphor nano-particles.

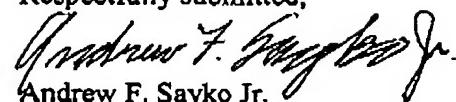
35. (New) A process for producing the non-aqueous sol-gel spin-on glass material of claim 18, the process comprising reacting an alkyl substituted trialkoxysilane or dialkyl substituted dialkoxy silane with a silane diol, wherein said alkyl group has from 1 to 8 carbon atoms, wherein the reaction of the alkyl substituted trialkoxysilane or dialkyl substituted dialkoxy silane with the silane diol is carried out in a non-aqueous medium in the presence of a catalyst, the process further comprising adding to said sol-gel spin-on glass material a phosphor dopant, which comprises YAG base phosphor or moisture sensitive phosphor nano-particles or an organic material selected from organic dyes or metal complexes.

36. (New) The process of claim 35, wherein the phosphor dopant comprises YAG base phosphor or moisture sensitive phosphor nano-particles.

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CERTIFICATE OF TRANSMISSION (37 CFR 1.8a AND 1.10)

I hereby certify that this correspondence (28 pages) is, on the date shown below, being transmitted by facsimile to the United States Patent and Trademark Office at Fax number (571) 273-8300.

Andrew F. Sayko Jr.:

Date: 27 September 2006